Categorical Standards Primer

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By the End of This Course

Be Able to...

- Identify Different Pretreatment Standards
- Differentiate Between Local Limits and Categorical Limits
- Correctly Apply Local and Categorical Limits

By the End of This Course

Be Able to...

- Determine an Industry's Categorical Designation and Limits
- Aware of Methodologies to Alter Categorical Limits
- Agree that Categorical Standards can be Ridiculously Complex

And hopefully remain conscious

Types of Pretreatment Standards Four Types (40 CFR 403) : General Prohibitions Specific Prohibitions Local Limits Categorical Standards Title 40 \rightarrow Chapter 1 \rightarrow Subchapter N \rightarrow Part 403 \rightarrow §403.1 Title 40: Protection of Environment PART 403-GENERAL PRETREATMENT REGULATIONS FOR EXISTING AND NEW SOURCES OF POLLUTION (a) This part implements sections 204(b)(1)(C), 208(b)(2) (C)(iii), 301(b)(1)(A)(ii), 301(b)(2) (A)(ii), 301 304 (e) and (g), 307, 308, 309, 402(b), 405, and 501(a) of the Federal Water Pollution Control Act as (a) This part implements sections 204(b)(1)(C), 208(b)(2) (C)(iii), 301(b)(1)(A)(ii), 301(b)(2) (A)(ii), 301(b)(A)(ii), 301(b)(2) (A)(ii), 301(b)(A)(ii), 3 (2), 304 (e) and (g), 307, 308, 309, 402(b), 405, and 501(a) of the Federal Water Pollution Control Act as at the state of the stabilishes responsibilities of Federal, state, and solve the stabilishes responsibilities of control pollutants (clean Water Act of 1977 (Pub. L. 95-217) or "The Act". It establishes responsibilities to control pollutants of control pollute to implement National Pretreatment Standards to control pollute to implement Clean Water Act of 1977 (Pub. L. 95-217) or "The Act". It establishes responsibilities of Federal, State, a government, industry and the public to implement National Pretreatment Standards to Control Polyukin or through or interfere with treatment processes in Public V Owned Treatment Works (POTWS) or which government, industry and the Public to implement National Pretreatment Standards to control poliutants through or interfere with treatment processes in Publicly Owned Treatment Works (POTWs) or which sewage sludge. Browse Next §403.1 Purpose and applicability. (h) This regulation applies: sewage sludge.

Types of Pretreatment Standards

General Prohibitions (403.5)

- Discharge cannot cause:
- Pass Through, or
- Interference

The <u>full</u> Eight Specific Prohibitions (403.5)

Discharge cannot cause:

- Fire or explosion hazard, flashpoint <140 F
- Corrosion, pH < 5.0</p>
- Obstruction to flow
- BOD causing interference
- Inhibition due to temperature, wastewater >104 F
- Petroleum/mineral oils causing interference
- Toxic gases
- Hauled pollutants, except as designated by POTW

Types of Pretreatment Standards

Local Limits (403.5)

- Developed by POTW
- Based on local conditions
- Apply to all permitted industries

Categorical Standards (403.6)

- Developed by EPA
- Technology based
- Apply to certain categories of industries

Overview of Categorical Standards



Effluent Guidelines are national regulatory standards for wastewater discharged to surface waters and municipal sewage treatment plants. EPA issues these regulations for industrial categories, based on the performance of treatment and control technologies.

Industry Regulations & Studies

All existing & proposed regulations, including:

- Federal Register ootices
- Support documents
- Industry studies

Ongoing Industry Studies

- Nutrient Removal & Secondary Technologies
- Centralized Waste Treatment
- Metai Finishing
 Petroleum Refining
 - oleum iertinung

 Developed and implemented by EPA's Effluent Guidelines Program

https://www.epa.gov/eg

- Targets the 126 Priority Pollutants
- 40CFR parts 405-471

Overview of Categorical Standards

You can find list of Categorical Industries here:

https://www.epa.gov/eg/ind ustrial-effluent-guidelines

Existing Regulations

The table below lists the Effluent Guidelines promulgated by EPA, organized by industry category.

- For some of the regulations, the links in the 'Category Overview' column provide a summary of the regulation and available EPA publications for the category.
- The links under '40 CFR' go directly to the **Code of Federal Regulations** (CFR). 'Initial' indicates the year of the first rulemaking for the category, and 'Last' indicates the most recent substantive revision.

Category Overview	\$ 40 CFR	Initial	≎ Last
Airport Deicing	<u>449</u>	2012	2012
Aluminum Forming	<u>467</u>	1983	1988
Asbestos Manufacturing	<u>427</u>	1974	1975
Battery Manufacturing	<u>461</u>	1984	1986
Canned and Preserved Fruits and Vegetable Processing	<u>407</u>	1974	1976
Canned and Preserved Seafood (Seafood Processing) ¹	<u>408</u>	1974	1975
Carbon Black Manufacturing	<u>458</u>	1976	1978
Cement Manufacturing	<u>411</u>	1974	1974
Centralized Waste Treatment ²	<u>437</u>	2000	2003
<u>Coal Mining</u>	<u>434</u>	1975	2002

Its got a Part! -

Its got Subparts!!

It even has Applicability!!!!!

And Standards too!

PART 469—ELECTRICAL AND ELECTRONIC COMPONENTS POINT

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§469.42 New source performance standards (NSPS).

§469.43 Pretreatment standards for new sources (PSNS).

Industry A began manufacturing gallium arsenide crystals for semi-conductors used in cell phones in 1998.

Which Category (i.e. Part)?

Click here for general description of industry & supporting documents

Click here for actual regulation

Initial publication year and most recent revision

Category Overview	\$ 40 CFR	Initial	≎ Last
Airport Deicing	449	2012	2012
Aluminum Forming	<u>467</u>	1983	1988
Asbestos Manufacturing	<u>427</u>	1974	1975
Battery Manufacturing	<u>461</u>	1984	1986
Canned and Preserved Fruits and Vegetable Processing	<u>407</u>	1974	1976
Canned and Preserved Seafood (Seafood Processing) ¹	<u>408</u>	1974	1975
Carbon Black Manufacturing	458	1976	1978
Cement Manufacturing	411	1974	1974
Centralized Waste Treatment ²	<u>437</u>	2000	2003
<u>Coal Mining</u>	434	1975	2002
Coil Coating	465	1982	1983
Concentrated Animal Feeding Operations (CAFO)	412	1974	2008
Concentrated Aquatic Animal Production (Aquaculture)	451	2004	2004
Construction and Development	<u>450</u>	2009	2014
Copper Forming	<u>468</u>	1983	1986
Dairy Products Processing	<u>405</u>	1974	1974
Electrical and Electronic Components	469	1983	1983
Electroplating	413	1974	1983
Explosives Manufacturing	<u>457</u>	1976	1976
Ferroalloy Manufacturing	424	1974	1974
Fertilizer Manufacturing	418	1974	1974
Glass Manufacturing	<u>426</u>	1974	1974
Grain Mills	406	1974	1974

Industry A began manufacturing gallium arsenide crystals for semiconductors used in cell phones in 1998. Which Category (i.e. Part)? Part 469 looks like a good fit! Which subpart?

Effluent Guidelines

- Effluent Guidelines Home Industry Regulations & Studies
- Learn About Effluent Guidelines Planning
- 2016 Plan Documents Annual Review Reports
- Implementation & Compliance

Electrical and Electronic **Components Effluent Guidelines**

EPA promulgated the Electrical and Electronic Components (E&EC) Effluent Guidelines and Standards (40 CFR Part 469) in 1983, The regulation covers direct and indirect dischargers. The E&EC Effluent Guidelines and Standards are incorporated into NPDES permi for direct dischargers, and permits or other control mechanisms for indirect dischargers (see Pretreatment Program).



Contect Lis Shere

On this page:

- What is the Electrical and Electronic Components Industry?
- Facilities Covered
- Guidance Documents
- **Rulemaking History**
- Additional Information

What is the Electrical and Electronic Components Industry?

E&EC facilities manufacture semiconductors, such as integrated circuits and light emitting diodes (LEDs): electronic crystals (made from quartz, ceramics and other materials), cathode ray tubes; and inescent materials used as coatings in fluorescent lamps.

Wastewater is generated from processes such as etching, cleaning, degreasing, cutting and grinding, Pollutants found in wastewaters include fluoride, arsenic and organic compounds.

Processes and Major Wastewater Sources

Processes	Description
Cutting and slicing	Crystals are cut or sliced using diamond blade saws or slurry saws. Water can be used for cooling and lubrication and to carry away removed material.
Lapping or	Mechanical grinders and chemical etchants are used to remove surface

Industry A began manufacturing gallium arsenide crystals for semi-conductors used in cell phones in 1998.

Which subpart?

Check applicability

PART 469—ELECTRICAL AND ELECTRONIC COMPONENTS POINT

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Subpart D—Luminescent Materials Subcategory

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§469.43 Pretreatment standards for new sources (PSNS).

Industry A beg manufacturing § crystals for semiused in cell pho Which subpart? Check applicab

Subpart B_Electronic Crystals Su (a) The provisions of the (b) IReserved §469.22 Specialized definitions.

The definitions in 40 CFR part 401 and the chemical analysis methods in 40 CFR part 136 apply to this subpart. In addition.

(a) The term "total toxic organics (TTO)" means the sum of the concentrations for each of the following toxic organic compounds which is found in the discharge at a concentration greater than ten (10) micrograms per liter:

1.2.4 Trichlorobenzene chloroform

1.2 Dichlorobenzene

1.3. Dichlorobenzene

1.4. Dichlorobenzene ethylbenzene

1,1,1 Trichloroethane methylene chloride naphthalene

2 Nitrophenol phenol bis (2-ethylhexyl) phthalate tetrachloroethylene toluene trichloroethylene

Beck to Top

\$469.20 Applicability.

2 Chlorophenol

2.4 Dichlorophenol

4 Nitrophenol pentachlorophenol di-n-butyl phthalate anthracene

1,2 Diphenylhydrazine isophorone butyl benzyl pthalate

1,1 Dichloroethylene

2.4.6 Trichlorophenol carbon tetrachloride

1.2 Dichloroethane

1.1.2 Trichloroethane dichlorobromomethane

(b) The term "electronic crystals" means crystals or crystalline material which because of their unique structural and electronic properties are used in electronic devices. Examples of these crystals are crystals comprised of quartz, ceramic, silicon, gallium arsenide, and idium arsenide.

(c) The term "manufacture of electronic crystals" means the growing of crystals and/or the production of crystal wafers for use in the manufacture of electronic devices.

Industry A began manufacturing gallium arsenide crystals for semi-conductors used in cell phones in 1998.

Applicable categorical regulation is 40 CFR 469 subpart B

Question: What categorical standards (i.e. limits) apply to this industry that is discharging to your POTW?

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§469.41	Specialized definitions.
§469.42	New source performance standards (NSPS).
§469.43	Pretreatment standards for new sources (PSNS).

New or existing

Source??

§469.26 Pretreatment standards for existing sources (PSES).

(a) Except as provided in 40 CFR 403.7 and 403.13, any existing source subject to this subpart which introduces pollutants into a publicly owned treatment works must comply with 40 CFR part 403 and achieve the following pretreatment standards for existing sources (PSES):

SUBPART B-ELECTRONIC CRYSTALS PSES EFFLUENT LIMITATIONS

				-
Pollutant or pollutant property	Maximum for any 1 d	lay	Average of daily values for 30 consecutive da	ys
		\leq	Milligrams per liter (mg/l)	
TTO ¹		1.37		Ċ
Arsenic (T) ³		2.09		0.8

¹Total toxic organics.

3 PP 27 New source performance Any new source subject to this s	e standards (NSPS). subpart must achieve the follo RT B—ELECTRONIC CRYSTAL	wing new source perform	ance standor & (NSPS):		
Pollutant or pollutant property TTO ¹ Arsenic(T) ³ Fluoride(T) TSS pH	Maximum 12 pay 1 day 1.37 2.09 32.0 61.0 (⁴)	Milligrams per liter(mg/l)	es for 30 consecutive day	(²) 0.83 17.4 23.0 (⁴)	
¹ Total toxic organics.	\$469. Ex owned sources (a) TTO ¹	8 Pretreatment standards cept as provided in 40 GFR 4 treatment works must comply s (PSNS): SUBPA utant or pollutant property	for new sources (PSNS). 193.7, any new source subject with 40 CFR part 403 and ac IRT B—ELECTRONIC CRYSTAL Maximum for any 1 day	t to this subpart which introduces the following pretreatmen S P SN S EFFLUENT LIMITATIONS Average of daily values for Milligrams per liter (mg/l)	pollutants into a publicly standards for new
	Arseni ¹ Ti	c (T) ³ otal toxic organics.	2.09	/	

What's a New Source?

40 CFR part 403.3 Definitions



§469.26 Pretreatment standards for existing sources (PSES).

(a) Except as provided in 40 CFR 403.7 and 403.13, any existing source subject to this subpart which introduces pollutants into a publicly owned treatment works must comply with 40 CFR part 403 and achieve the following pretreatment standards for existing sources (PSES):

SUBPART B-ELECTRONIC CRYSTALS PSES EFFLUENT LIMITATIONS

Pollutant or pollutant property	ty Maximum for any 1 day Average of daily values for 30 consecuti		
	Milligrams per liter (mg/l)		
TTO1	1.37	(²)	
Arsenic (T) ³	2.09	0.83	

¹Total toxic organics.

§469.28 Pretreatment standards for new sources (PSNS).

Except as provided in 40 CFR 403.7, any new source subject to this subpart which introduces pollutants into a publicly owned treatment works must comply with 40 CFR part 403 and achieve the following pretreatment standards for new sources (PSNS):

(a)

SUBPART B-ELECTRONIC CRYSTALS PSN'S EFFLUENT LIMITATIONS

Pollutant or pollutant property	Maximum for any 1 day	Average of daily values for 30 consecutive days
		Milligrams per liter (mg/l)
TTO ¹	1.37	(2)
Arsenic (T) ³	2.09	0.83

¹Total toxic organics.

Manufacturing Began - 1998 Rule Published -1983 **New Source 469.28 applies**

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Cement Manufacturing	<u>411</u>	1974	1974
Centralized Waste Treatment ²	<u>437</u>	2000	2003
Coal Mining	434	1975	2002
Coil Coating	<u>465</u>	1982	1983
Concentrated Animal Feeding Operations (CAFO)	412	1974	2008
Concentrated Aquatic Animal Production (Aquaculture)	451	2004	2004
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Dairy Products Processing	<u>405</u>	1974	1974
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Electroplating	<u>413</u>	1974	1983
Explosives Manufacturing	<u>457</u>	1976	1976
Ferroalloy Manufacturing	<u>424</u>	1974	1974
Fertilizer Manufacturing	418	1974	1974
Glass Manufacturing	<u>426</u>	1974	1974
Grain Mills	406	1974	1974

Local Limits vs. Categorical Standards Where to apply limits?





Local Limits vs. Categorical Standards Where to apply limits?



Local Limits vs. Categorical Standards Where to apply limits?







Adjusting Cat. Limits:

Combined Waste Stream Formula

$$C_{AL} = \frac{\sum_{i=1}^{N} C_i F_i}{\sum_{i=1}^{N} F_i} \left(\frac{F_{AL} - F_D}{F_{AL}} \right)$$

Flow Weighted Average

$$C_{AD} = \frac{\sum_{i=1}^{NA} C_{AL_i} F_{AL_i} + \sum_{i=1}^{NC} C_{u_i} F_{u_i}}{F_{AD}}$$

Commingling of Waste Streams CWF or FWA terms to know:



Guidance Manual for the Use of Production Based Pretreatment Standards and the <u>Combined Wastestream Formula</u>, September 1985

EPA Number: 833/B-85-201

https://www3.epa.gov/npdes/pubs/owm026 0.pdf

Industry X began manufacturing photovoltaic cell modules (PVs), using a stainless steel foil as a substrate in 2005.

Which subpart?

Hint: Photovoltaic cells are a type of semi-conductor

PART 469—ELECTRICAL AND ELECTRONIC COMPONENTS POINT

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\$469.18 Pretreatment standards for new sources (PSNS).
\$469.19 Effluent limitations representing the degree of effluent reduction attainable b technology (BCT).

Subpart B—Electronic Crystals Subcategory

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§469.22 Specialized definitions.
§469.23 Monitoring.
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Subpart C—Cathode Ray Tube Subcategory

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Subpart D—Luminescent Materials Subcategory

§469.40 Applicability.
§469.41 Specialized definitions.
§469.42 New source performance standards (NSPS).
§469.43 Pretreatment standards for new sources (PSNS).

Industry X began manufacturing photovoltaic cell modules (PVs), using a stainless steel foil as a substrate in 2005.

Which subpart?

Subpart A—Semiconductor Subcategory

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§469.10 Applicability.

The provisions of this subpart are applicable to discharges resulting from all process operations associated with the manufacture of semiconductors, except sputtering, vapor deposition, and electroplating.

(b) The term "semiconductors" means solid state electrical devices which perform functions such as information processing and display, power bandling, and interconversion between light energy and electrical energy.

(c) The term "manufacture of semiconductors" means those processes, beginning with the use of crystal wafers, which lead to or are as ociated with the manufacture of semiconductor devices.

Industry X began manufacturing photovoltaic cell modules (PVs), using a stainless steel foil as a substrate in 2005.

More information about process:

Circuitry is placed on the foil substrate through sputtering, electro-deposition (plating), and screen printing.

Which category?

Industry X began manufacturing (PVs), using a stainless, substrate in photovoltaic cell modules Subpart A Applicability;

More information process:

o discharges from a Circuitry is place substrate through s electro-deposition (pl and screen printing.

Which category?

Part 433

	Iron and Steel Manufacturing	<u>420</u>	1974	2005
	Landfills	<u>445</u>	2000	2000
	Leather Tanning and Finishing	<u>425</u>	1982	1996
	Meat and Poultry Products	<u>432</u>	1974	2004
Julies	Metal Finishing ²	<u>433</u>	1983	1986
Sauboan	Metal Molding and Casting (Foundries)	<u>464</u>	1985	1985
\$433.10 100 1	Products and Machinery	<u>438</u>	2003	2003
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How Different Can Categorical Regulations Be?

- For each industry discharging to your POTW, determine if it is required to have a CIU permit:
 - A Simple Slaughterhouse
 - Soap Manufacturer
 - Øil Based Paint Formulator
 - Roofing Asphalt Emulsions Production Plant

How Different Can Categorical **Regulations Be?**

A Simple Slaughterhouse? SU2.14 Fretreament sambards for existing sources IPSESI. Reserved

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- \$432.17 Effluent limitations attainable by the application of the best control technology for conventional pollutants (BCT).

Subpart B—Complex Slaughterhouses

- §432.20 Applicability.
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- §432.22 Effluent limitations attainable by the application of the best practicable control technology currently available (BPT).
- §432.23 Effluent limitations attainable by the application of the best available technology economically achievable (BAT).
- 32.24 Pretreatment standards for existing sources (PSES). [Reserved]
- 2.25 New source performance standards (NSPS).
 - Pretreatment standards for new sources (PSNS). [Reserved]

Effluent limitations attainable by the application of the best control technology for conventional pollutants (BCT).

Low-processing Packinghouses

nt limitations attainable by the application of the best practicable control technology currently available (BPT). fluent limitations attainable by the application of the best available technology economically achievable (BAT).

- Pretreatment standards for existing sources (PSES). [Reserved]
- New source performance standards (NSPS).
- 432.38 Pretreatment standards for new sources (PSNS). [Reserved]
- \$432.37 Effluent limitations attainable by the application of the best control technology for conventional pollutants (BCT).

Subpart D—High-Processing Packinghouse

- \$432.40 Applicability.
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- §432.44 Pretreatment standards for existing sources (PSES). [Reserved]
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- \$432.57 Effluent limitations attainable by the application of the best control technology for conventional pollutants (BCT).

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- §432.60 Applicability.
- 6432.61 Special definitions
- §432.62 Effluent limitations attainable by the application of the best practicable control technology currently available (BPT). \$432.63 Effluent limitations attainable by the application of the best available technology economically achievable (BAT).
- §432.64 Pretreatment standards for existing sources (PSES). [Reserved]
- §432.65 New source performance standards (NSPS).
- §432.66 Pretreatment standards for new sources (PSNS). [Reserved]
- §432.87 Effluent limitations attainable by the application of the best control technology for conventional pollutants (BCT).

Subpart G—Sausage and Luncheon Meats Processors

How Different Can Categorical **Regulations Be?**

Soap Manufacturer NO

If it meets SIU criteria, then permit as a non-S417.16 Pretreatment stand ds for new sources. S417.16 Pretreatment stand ds for new sources process westernater pollutens into a publicly owned treatment stand ds for new sources process westernater pollutens into a publicly owned treatment source subject to this subject to the su

Title 40: Protection of Environment

PART 417—SOAP AND DETERGENT MANUFACTURING POINT SOURCE CATEGORY

Contents

Subpart A—Soap Manufacturing by Batch Kettle Subcategory

- §417.10 Applicability; description of the soap manufacturing by batch kettle subcategory.
- §417.11 Specialized definitions
- \$417.12 Effluent limitations guidelines representing the degree of effluent reduction attainable by the application of the best practicable control technology currently available.
- \$417.13 Effluent limitations guidelines representing the degree of effluent reduction attainable by the application of the best available technology economically achievable.
- §417.14 Pretreatment standards for existing sources.
- §417.15 Standards of performance for new sources.
 - §417.18 Pretreatment standards for new so

t Splitting Subcategory

cturing by fat splitting subcategory.

egree of effluent reduction attainable by the application of the best practicable control

enting the degree of effluent reduction attainable by the application of the best available

part C—Soap Manufacturing by Fatty Acid Neutralization Subcategory

§417.30 Applicability; description of the soap manufacturing by fatty acid neutralization subcategory.

§417.32 Effluent limitations guidelines representing the degree of effluent reduction attainable by the application of the best practicable control

§417.33 Effluent limitations guidelines representing the degree of effluent reduction attainable by the application of the best available

Subpart D—Glycerine Concentration Subcategory





works must comply with 40 CFR part 403. In addition, the following pretreatment standard establishes the quantity or quality of pollutants or pollutant properties controlled by this section which may be discharged to a publicly owned treatment works by a new source subject to the provisions of this subpart:

Pollutant or pollutant property	Pretreatment standard
BOD₅	No limitation.
TSS	Do.
pН	Do
Oil and grease	100 mg/l.



Ho	ow Differer	nt Can	
Catego	orical Regu	lations B	eś
Different Types Mass Based Limits	of Limits	Applicability; description of the subcate rovisions of this subpart are applicable to products and product groups of	Tory of in a
PART 414—ORGANIC CHEMICALS, PLASTICS, A Contents	(a) Any poin autiplying the price concentrations lister cyanic	t source subject to this subpart mu poess wastewater flow subpart mu	Process wastewater discharge point sources.
Subpart A—General §414.10 General definitions. §414.11 Applicability. §414.12 Compliance date for pretreatment standards for exis	OCPSF bearing was bearing based upon a c such streams designated Appendix A waste streams unless the review of rela	In the following table to this subject to this subject on the following table to this subject to a streams are defined as the pollutants time water streams identified by the wasts or to the d as metal to that such that the dots wasts or to to the streams the streams for to the to t	Voint sources. Vischarges not exceeding the quantity (manual for the formation state of the formation state of the formation for the formation of the formation
Subpart B—Rayon Fibers	Acenaphthene Acenaphthene Anthracene Benzene Bis(2-ethylhexyl) phthalate Chlorobenzene Chloroterna Chloroterna Chloroterna Chloroterna Chloroterna Chloroterna Chloroterna	support of a streams control authors is the control authors is will result in substantial example of the streams contain signific ing, production, and sampling and analysis information of these points in the stream of the set of the stream of the set of	cyanide. The metal-bearing waste streams listed in Appendix A of this part, plus and an yon a case-by-case basis as metal or cyanid independently of other metal or cyanid south amounts of the pollutants identified about listed in Appendix A of this part, plus any add independently of other metal or cyanid listens. This determination must be based by and PSNS1 Maximum for
	1.2-Dichlorobenzene 1.4-Dichlorobenzene 1.1-Dichlorobenzene 1.2-Dichloroethane	$ \begin{array}{r} 134 \\ 258 \\ 380 \\ 295 \\ 325 \\ 325 \\ 43 \\ 794 \\ 380 \\ 380 $	10° any monthly average 10 19 19 19 19 19 19 19 19 19 19 19 19 19

How Different Can
Categorical Regulations Be?
Different Types of Limits
Production Based Limits
PART 464—METAL MOLDING AND CASTING POINT SOURCE CATEGORY
Contents GENERAL PROVISIONS
§464.01 Applicability. §464.02 General definitions. §464.03 Monitoring and reporting requirements. §464.04 Compliance date for PSES.
Subpart A-Aluminum Casting Subcategory Prefre provideo must provideo pr
§404.10 Applicability; description of the aluminum care Extremain of the aluminum care §404.11 Specialized definitions. §404.12 Effluent limitations guidelines representing the sources. Cleaning of the aluminum care sources Casting primarily mail are costing to primarily row where presenting the sources. (a) primarily gray iron where are of the analytic property (b) primarily gray iron where are only on the analytic property (a) primarily gray iron where are only on the analytic property (b) primarily gray iron where are only on the analytic property (casting primarily gray iron where are only on the analytic property of
Pollutant or per Pollutant or per Conter [1] Conter [1]

How Different Can			
Categorical Regulations Be?			
Different Types of Lir	mits	subpart that introduces	
Best Management Plans Note: The standards for existing sources (PSES). Best Management Plans AD CFR 403.7 and 403.13, any existing source subject to this subject to the subject to the subject to this subject to the subject			
PART 433—METAL FINISHING POINT SOU	a) Except as provided in our reatment with tants into a publicly owned treatment standards for existing sources (reatment standards for existing SexCEPT J	(PSES): JOB SHOPS AND INDEPENDENT PRIMA JOB SHOPS AND INDEPENDENT PRIMA JOB SHOPS AND INDEPENDENT PRIMA Monthly average shall not en- 0.26 0.26 1.71 0.27	
Subpart A—Metal Finishing Subcategory	PSES FORTH Pollutant or pollutant property	Maximu 0.89 0.43 2.77 2.38 3.38 0.24 0.69 1.48	
 §433.10 Applicability; description of the metal finishing po §433.11 Specialized definitions. §433.12 Monitoring requirements. §433.13 Effluent limitations representing the degree of effluent limitations. 	Cadmium (T) Chromium (T) Copper (T)	3.98 0.43 2.61 1.20 biot 10 those ingit	
available (BPT). §433.14 Effluent limitations representing the degree of efflue achievable (BAT).	Lead (1) Nickel (T) 6 Silvet (T) Zinc (T) Cvanide (T)	2.13 2.13 2.13 2.13 2.13 2.13 2.13 2.13	
 §433.15 Pretreatment standards for existing sources (PSES §433.16 New source performance standards (NSPS). §433.17 Pretreatment standards for new sources (PSNS). 	(b) Alternatively, for industrial f (b) Alternatively, for industrial f limits and the pollution control auth limits and the pollution control auth sized in paragraph (a) of this s	I facilities we following arrow Monthly average 0.32 thority. The following arrow 0.32 section: 0.80 merty 0.80 to under the provisions of this	
Subpart B [Reserved]	Pollutant or pollutant pro	estewater pollutants into a publicly owned treatment works United and the advance treatment works United and the advance treatment works United and the advance treatment was the set of the advance to \$433.12 (a) and (b) of this regulation	
(c) No user introducing wascerprocess wascer (c) No user introducing wascerprocess wascer subpart shall augment the use of process wascer subpart shall augment the use of process wascer subpart shall augment the use of process wascerprocess wascerproces wascerprocess wascerprocess wascerproces wascerprocess w			
TOMP	(d) An existing source must implement the toxic or (e) An existing source	Se subject to this subpert shelf and	



Resource for Categorical Overview



You (yes, even you!) Can Adjust Categorical Standards

40 CFR 403 - 7 ways to alter numerical standards

- I. Combined Waste Stream Formula
- 2. Flow Weighted Averages
- 3. Removal Credits
 - CIU gets limit(s) reduced based on POTWs ability to remove regulated pollutant
 - Burden on POTW to demonstrate its ability to treat IU's categorical pollutant

Fundamentally Different Factors Variance – CIU demonstrates operation is fundamentally different than those EPA considered when developing rule

You (yes, even you!) Can Adjust Categorical Standards

- Net/Gross Adjustment CIU can receive credit for pollutant demonstrated to be in its source water.
- Equivalent mass limits CA can convert conc. limits to mass if CIU demonstrates need for water conservation efforts
- 7. Equivalent Conc. Limits for Mass Based Standards

6&7 are optional Streamlining changes, must be adopted into SUO



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